HL-LHC beam parameters at injection

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Beam and machine parameters: SPS

- Q20 optics $(\gamma_t = 18)$
- Assumed longitudinal particle distribution (reconstructed without intensity effects from the best fit to measured bunch profiles at 450 GeV):

$$F(J) = (1 - J/J_0)^{3/2}$$

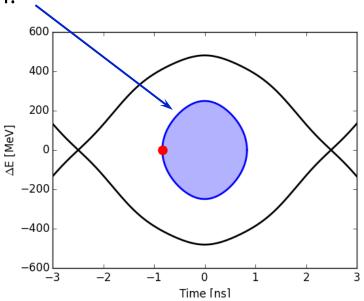
- Impedance used in simulations: ImZ/n = 3.5 Ohm
- Two cases considered:
 - 1. Target bunch length tau = 1.67 ns (4σ Gaussian fit as used now in measurements)
 - \rightarrow Max N_b = 2.0 x 10¹¹, with V₂₀₀ = 11.5 MV (estimated value taking into account beam loading for 25 ns beam) and V₈₀₀ = 1.15 MV. Bunch length of 1.67 ns is obtained for beam induced voltage with ImZ/n = 3.5 Ohm.
 - 2. Target intensity $N_b = 2.3 \times 10^{11}$ \rightarrow Min bunch length = 1.83 ns, with $V_{200} = 10$ MV, $V_{800} = 1.0$ MV

Beam and machine parameters: HL-LHC

- 450 GeV/c
- $\gamma_{+} = 53.789$
- $V_{400} = 8 \text{ MV}$
- Longitudinal impedance: $ImZ/n = 0.11 \Omega$
- Two cases considered at injection (1st turn):
 - $-N = 2.0x10^{11}$, $\tau = 1.67$ ns
 - $-N = 2.3x10^{11}$, $\tau = 1.83$ ns

Beam parameters: definitions

- Full bunch length → 3 methods used:
 - Gaussian fit $(4\sigma_t)$,
 - 4 x rms,
 - $-\frac{2}{\sqrt{2 \ln 2}}$ FWHM.
- From the trajectory of a particle with a synchrotron oscillation amplitude corresponding to the full bunch length:
 - \rightarrow Energy spread Δ E (maximum)
 - → Emittance (area)



Beam parameters at SPS/LHC transfer

		SPS at extraction LHC 1 st turn			LHC after capture (after ~100ms)		
N_b		Gaussian fit	rms	FWHM	Gaussian fit	rms	FWHM
2.0 x 10 ¹¹	Bunch length [ns]	1.670	1.582	1.712	1.316	1.281	1.332
	Energy spread [10 ⁻³]	0.536	0.514	0.547	0.705	0.691	0.712
	Emittance [eVs]	0.610	0.555	0.637	0.636	0.607	0.649
2.3 x 10 ¹¹	Bunch length [ns]	1.830	1.737	1.877	1.391	1.386	1.411
	Energy spread [10 ⁻³]	0.535	0.513	0.543	0.735	0.733	0.743
	Emittance [eVs]	0.665	0.606	0.689	0.698	0.693	0.714